SEC. 219. NATIONAL STRATEGY ON THE MICROELECTRONICS INDUSTRIAL BASE.

(a) In General.—Not later than 1 year after the date of the enactment of this Act, the President shall issue a national strategy for supporting and fostering the domestic microelectronics industrial base to support defense, national security, and national economic priorities.

(b) Elements.—The strategy required by subsection (a) shall include the following:

(1) Goals for assessing the health and viability of the domestic microelectronics industrial base to support production of state of the art practice and next generation designs, tools, and production capabilities.

(2) Identification of opportunities to link government design and development capabilities with domestic industrial base providers to develop public-private partnerships for sustaining and developing
state of the art microelectronics foundry designs, tools, and production capabilities.

(3) Recommendations for improving the synchronization of review and assessment of foreign acquisition or technology transfer for microelectronics intellectual policy impacting the domestic microelectronics industrial base, including coordination with international partners and allied governments.

(4) Improvements to the interagency coordination and enforcement of the use and integration of trusted microelectronics in critical national security systems.

(5) Identification of known or suspected violations of World Trade Organization rules by domestic or foreign competitors in the microelectronics industrial base, including recommendations for responding to such violations.

(6) Recommendations for incentives at the Federal, State, and local level to attract and retain investment in businesses in the microelectronics sector, including adjustments to tax and trade policy.

(c) FORM.—The strategy required by subsection (a) shall be unclassified, but may include a classified annex.